METHODS OF COATING FABRICATION

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The coating is the thin outer layer of the object, which physiochemical properties and/or structure are different from those of the coated material.
METHODS OF COATINGS FABRICATION

1. Electrolytic method
2. Anodic oxide film
3. Chemical methods
4. Immersion method
5. Thermal spraying
6. Diffusion methods
7. Platening
8. Vacuum deposition of electroless methods
1. Mechanical methods:
   - abrasing and/or polishing,
   - brushing

2. Physico-chemical methods:
   - degreasing in solvents
   - emulsion degreasing,
   - alkaline degreasing,
   - etching in acids and bases (removing of oxides and hydroxides)
   - electrolytic degreasing,
   - degreasing using ultrasounds

Electrolytic metal coatings produced on the conductive substrate are obtained by deposition of metals from a solution of their salts or anodes made from appropriate metal, using electric current. The coated object is the cathode and the anode constitutes the plating material. Coatings are obtained in the first stage by the formation of crystallization centers, which subsequently grow to form a continuous layer with required thickness.

Factors affecting the properties of the coatings: the type of metal substrate, type and concentration of additives (e.g., increasing the electrical conductivity of the bath, causing the formation of finely coating or brightening shell), current density, bath temperature, time of the process and methods of mixing the bath (mechanical, compressed air, etc.).
ELECTROLYTIC COATINGS (GALVANIC)
ELECTROLYTIC COATINGS (GALVANIC)

Theory diagram for the electrolysis of COPPER(II) SULFATE SOLUTION with CARBON ELECTRODES

- Deposit of copper metal on electrode surface
- Positive ions are attracted to the negative electrode, gain electrons, so are reduced (REDUCTION)
- Electrolyte of dilute copper sulfate solution
- Negative ions are attracted to the positive electrode, lose electrons, so are oxidised (OXIDATION)

Method of collecting electrode products ignored in this diagram

(c) doc b
Anodic oxide film

Structure of porous anodic oxide film, formed on aluminum in acid solutions
Anodic oxide film

Coloring of porous type anodic oxide films on aluminum:

a) integral coloring,
b) dyeing
c) electrolytic coloring
Process of pore sealing with hydroxide during dipping in boiling pure water
TEM image of the vertical section of a porous type anodic film on aluminum
Chemical (electroless) imposition of metals involves the reduction of metal compounds from solutions of their salts by using reducers (hypophosphoric acid salts, or other). Until now chemical methods are developed, consisting in chemical vapor deposition of nickel, cobalt, tin, copper, silver, gold, palladium or platinum. The contact coating method consists in displacement of the metal ions from solution by the metal substrate. Metallic coatings deposited by chemical methods are rarely used for protection against high temperature corrosion.

\[ M^{x+} + \text{Red}_{\text{solution}} \xrightarrow{\text{catalytic surface}} M_{\text{solid}} + \text{Oxy}_{\text{solution}} \]
Hot-dip coatings are obtained by immersion of a given material in a molten metal bath. This method is the oldest and cheapest one, currently utilized in obtaining metallic coatings, well adherent to the substrate. This method is mainly used in those cases when the material shows considerable length (tapes, wires).

This method can be applied only when the melting point of a given material is higher than that of the coating. In practice, this method is used for coating tin (232°C), lead (327°C), zinc (419°C) and aluminum (660°C).
HOT–DIP COATING (DIP COATING)
- scheme of device for hot-dip tinning

1 – oil, 2 - cylinder head, 3 – fluxing agent, 4 - molten tin
Thermal metal spraying involves melting, using different heat sources (flame, electric arc, plasma arc or high-frequency current). The metal for coating production is used in the form of wire or powder, which after melting is directed to the substrate in a stream of compressed gas (usually air). In the high temperature flame or arc, metal particles are partially oxidized, and after hitting the ground are flattened. During hitting of the ground the oxide thin film is cracking and consequently the coating constitutes a shell of sprayed metal, its oxide and pores. The total pore volume generally does not exceed 15%.
THERMALLY SPRAYED COATING
Scheme formation of the sprayed metal layer

1 - oxide on particle film, 2 - the liquid inside the particle, 3 - particle splash during impact,
4 - rest of the oxide film between sprayed particles, 5 - jamming the particles,
6 - particles coupled by mutual welding, 7 - particle at low temperature (not plastic),
8 - the gap between the particles (not plastic), 9 - micropores (developed due to trapped of
exhaust gas between particles, 10 - surface of the substrate, 11 - substrate
THERMALLY SPRAYED COATING

Forms of porosity in thermal spray coating
Diffusion coatings are produced by changing the chemical composition of the surface layer of a given material as a result of the introduction of alien elements. Diffusion coating is a part of the substrate material saturated with alien elements, which cannot be separated from it. Metals plated on the substrate surface diffuse into the crystal lattice, not influencing the apparent changes of its dimensions.

Typical diffusion processes:

- Aluminizing
- Chrome plating
- Chrome aluminizing
- Galvanizing
- Chrome siliconizing
Schematic diagram of the apparatus used for aluminizing by pack cementation.
Progressive stages of aluminization in a low-activity aluminum pack:

a) pure nickel
b) nickel-base superalloy
DIFFUSION COATINGS

Plating method consists in mechanical coating of a relatively thick layers of a given metal on protected substrate, being in the form of tape or wire. Metal coating (more noble or more decorative) can be obtained by casting, welding, soldering, rolling or explosive plating. The penetration of the coating metal into the substrate proceeds under the influence of pressure and temperature, providing the welding. Carbon steels are usually plating by copper, nickel, aluminum and acid resistant steels.
BASIC ION PLATING PROCESS
METHOD OF EXPLOSIVE PLATING

a) planar system, b) cylindrical system; 1 – explosive material
2 – detonator, 3 – material applied as a coating,
4 – substrate
Methods of vacuum deposition of metals:
- Electroless vacuum deposition
- Cathodic sputtering
- Ionic metallization
BASIC SPUTTERING PROCESS
Cross-section of the Ni-Cr-Al-Y coating obtained by the EB-PVD method
Surface and cross-section of the Co-Cr-Al-Y coating obtained by the EB-PVD method on the IN-738 alloy
BASIC EVAPORATION PROCESS
THE END